



INFORMATION DISCLOSURE CITATION
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Applicant(s)
Michael J. Scaggs

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09/30/2002

Group Art Unit
Unknown

U.S. PATENT DOCUMENTS

*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE
RRB	AA	3,679,863	07/25/1972	Houldcroft et al.	219	121 LM	11/10/1969
↑	AB	3,749,878	07/31/1973	Sullivan et al.	219	121 L	01/19/1971
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							Yes	No
	BC	10-99978	04/21/1998	Japan	B-23 K	26/00	Abstract	
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BH	S. Zhu, et al., "Laser ablation of solid substrates in a water confined environment," <i>Applied Physics Letters</i> , Vol. 79, No. 9, 27 August 2001, pp. 1396-1398.

Examiner

R. Burkh

Date Considered

7-2005 and 3-2006

Examiner: Initial if citation considered, whether or not citation is in conformance with MPEP Section 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.